

**Notice of References Cited**

Application/Control No.

09/836,884

Applicant(s)/Patent Under

Reexamination

DENIS ET AL.

Examiner

Khiem D Nguyen

Art Unit

2823

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**NON-PATENT DOCUMENTS**

*		Include as applicable: Author, Title Date, Publisher, Edition or Volume, Pertinent Pages
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\*A copy of this reference is not being furnished with this Office action. (See MPEP § 707.05(a).)

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